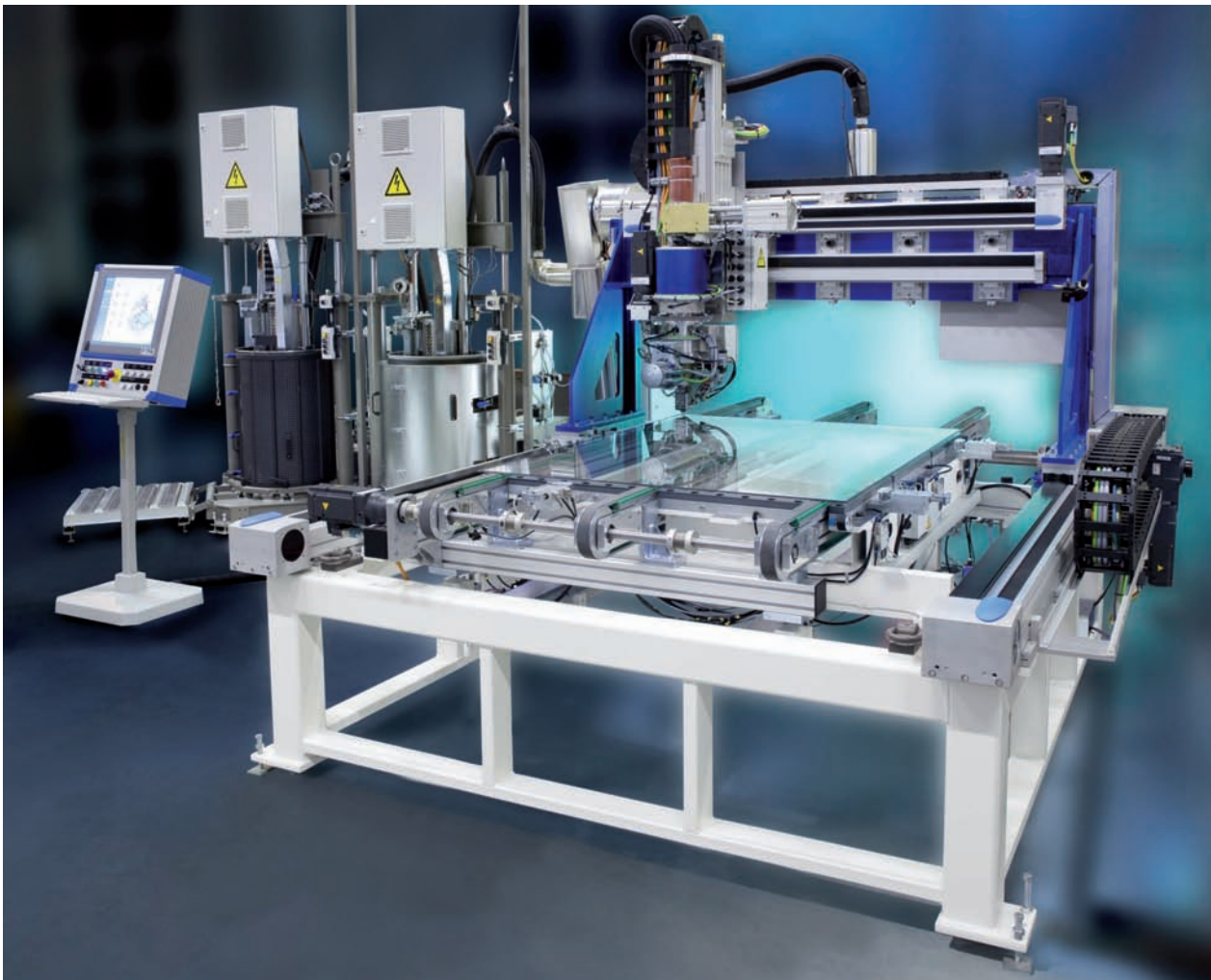


System solution for butyl sealing

Efficient moisture prevention for sensible thin film substrates

- ◆ Horizontal application system for active and effective vapour barrier prior to lamination process
- ◆ Highest available butyl sealing precision
- ◆ Real 24 h / 7 days per week production without interruption
- ◆ Best technology for fast and efficient production

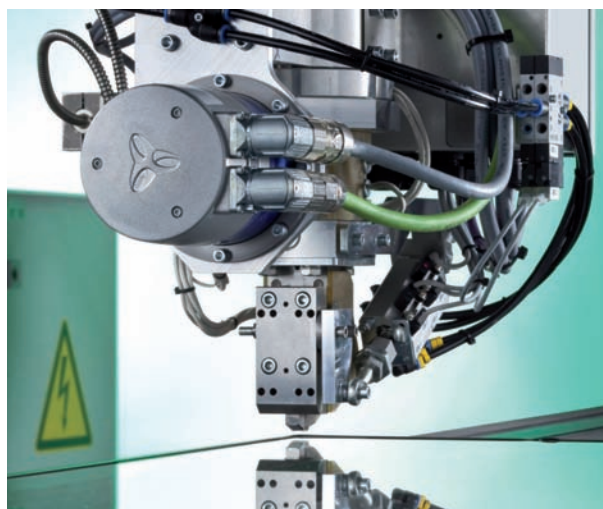


- ◆ Individually adjustable application heights of butyl material
- ◆ Completely non-stop application via high performance two drum pump system
- ◆ User-friendly operation system
- ◆ Tested with different lamination systems
- ◆ Available also as tandem application system with cycle times under 30 seconds per substrate
- ◆ Integration into newly designed plants as well as into existing production lines

Option:

- ◆ Butyl sealing for junction boxes

Technical data	
Glass size	upon request
Glass thickness	upon request
Application height	0.5 – 1.0 mm (0.02 – 0.04 in.) others upon request
Working height	upon request



Highest available butyl sealing precision



Active and effective vapour barrier prior to lamination process

Different application processes

- ◆ Interruption-free application at the corners
- ◆ Completely tight application
- ◆ Interruption between the application at the corners
- ◆ Corners are closed during the lamination process

